

Commissioning and Stability Studies of the SwissFEL Bunch-separation System

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ABSTRACT

SwissFEL is a linear electron accelerator based, Xray Free Electron Laser at the Paul Scherrer Institute, Switzerland. It is a user oriented facility capable of producing short, high brightness X-ray pulses covering the spectral range from 1 to 50 Å. SwissFEL is designed to run in two electron bunch mode in order to serve simultaneously two experimental beamline stations (hard and soft X-ray one) at its full repetition rate. Two closely spaced (28 ns) electron bunches are accelerated in one RF macro pulse up to 3 GeV. A high stability resonant kicker system and a Lambertson septum magnet are used to separate the bunches and to send them to their respective beamlines. With the advancement of the construction of the second beamline (Athos) the bunch-separation system was successfully commissioned. In order to confirm that the beam separation process is fully transparent a stability study of the electron beam and the free electron laser in the main beamline (Aramis) was done.



SwissFEL

RESONANT KICKER (RK) SCHEME



Deflecting current is slowly excited in the RKs. The two bunches arrive at the positive and negative maximum of the deflecting current or magnetic field.

719 m

→ Schematic representation of SwissFEL double bunch operation scheme.

Beam trajectories of the straight and deflected Q beam. The color rectangles represent the Q Deflected beam corresponding magnets' field regions. K2 **K**1 10 mm Enlarged view of the trajectories through K1 Straight beam and K2 region. The arrows represent the direction of the electron deflection force. Vacuum chamber K Machine axis, m Straight beam Legend: Kx – Kicker magnet D2D1Dx – Dipole magnet S – Septum magnet Q – Quadrupole magnet 264 Machine axis, m

ELECTRON BEAM STABILITY

Electron beam position right before the FEL

e- beam position SARUN02-DBPM070

BEAM TRAJECTORIES

undulator section. Running standard deviation of 100 consecutive pulses.

No visible difference in ebeam position stability with and without bunchseparation.



FEL PHOTON BEAM STABILITY



Pulse-to-pulse stability is not affected by bunchseparation system.





ENVELOPE, PHASE SCAN AND BUNCH SEPARATION

Finding rough position of the RKs' resonance. Resonance development appears backwards due to the increase in the relative delay between beam and RK macropulse in the scan.

> Fine scan for phase determination. E-beam "probes" the sine wave of the RKs.

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Vertical trajectory in the two electron beamlines (bunch separation).





Aramis Bunch 1 Aramis: V

Aramis: Vert. Position Y (Bunch 1)



CONCLUSION

Aramis beamline of SwissFEL is in regular user operation. Commissioning of the second beamline (Athos) is on its way. A fully transparent operation of the bunch-separation system is crucial to the efficient operation of SwissFEL. Number of tests were conducted to check its effect on the electron beam and FEL. It was confirmed that for the level of stability of the Aramis FEL beam present for our measurements, the bunch-separation system did not add any additional jitter to the FEL pointing and pulse energy.

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